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Effect of Bonding Temperature on Microstructure and Mechanical Properties during TLP Bonding of GH4169 Superalloy

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Abstract: The effect of bonding temperature on the microstructure and mechanical properties of transient liquid phase (TLP) joints of GH4169 superalloy was investigated. Joining processes were carried out at 1040–1100 °C for 30 min using BNi-2 solder paste. The results showed that three distinct microstructural zones were formed in the joint region: an athermal solidification zone (ASZ), consisting of eutectic compounds; an isothermal solidification zone (ISZ), consisting of γ solid solution; and a diffusion affected zone (DAZ), consisting of Ni-Cr rich boride and Cr-Nb-Mo-rich boride compounds. With increasing bonding temperature, the amounts of eutectic compounds in ASZ first decreased and then increased. A eutectic-free joint centerline was obtained at 1080 °C. The maximum bonding shear strength reached 728.03 MPa due to the completion of isothermal solidification. Fractographic studies revealed that the boride compounds in ASZ and the intermetallic compounds in DAZ were the main causes for the failure of joints. The fracture mode of the sample bonded at 1080 °C was ductile, and the fracture path was along the ASZ. However, the fracture mode of the sample bonded at 1080 °C was ductile, and the fracture occurred along the DAZ.

Keywords: TLP bonding; GH4169 superalloy; BNi-2 solder paste; microstructure; shear strength

1. Introduction

GH4169 is a precipitation-strengthened nickel-base superalloy with excellent fatigue resistance, radiation resistance, oxidation resistance, and corrosion resistance below 650 °C [1–3]. It is widely used in aerospace engines, nuclear reactors, petroleum pumps, and extrusion molds [4,5]. During the aging process, face-centered cubic γ' phase (Ni₃Al, Ni₃Ti, Ni₃(Al, Ti)) and metastable body-centered tetragonal γ'' phase (Ni₃Nb) would form in GH4169 alloy. The high strength of GH4169 is caused by the precipitation strengthening of the γ'' phase [6,7].

GH4169 nickel-base alloys are costly. Defective parts are often repaired by welding rather than being replaced. For example, some turbine engine components (e.g., racks, blades) may be repaired several times during service [8,9]. The welding of nickel-base alloys is usually difficult. Even with laser beam welding and electron beam welding, harmful intermetallic compounds inevitably form in the welding zone, which lead to the deterioration of the mechanical properties of the joints [10–14]. In order to solve the problems during the welding process, some researchers have tried transient liquid phase (TLP) bonding technology to join nickel-base alloys. Pouranvari et al. [15] brazed IN718 using the TLP method, in which a Ni-Si-B ternary alloy was used as the filler metal. The results showed that the mechanical properties of the joint mainly depend on the precipitation of the eutectic phase during solidification. Abdolvand et al. [16] studied TLP bonding of SAF2507 and AISI304 stainless steel using

BNi-2 amorphous foil and found that the intermetallic compounds in the joint center decreased with the prolongation of holding time at a set temperature. A joint free of intermetallic compounds was obtained at 1050 °C for 45 min. The TLP bonding of IN718 and IN625 nickel-base alloys using a BNi-2 interlayer was investigated by Arafin et al. [17]. It was suggested that the proper bonding temperature should be between 1050 and 1120 °C.

At present, the welding of GH4169 nickel-base alloy is also very difficult. Solid-state solder foils are most commonly used in the welding of GH4169 alloy in industry. As for solder foils, they need to be stamped into the required shape and size during practical application. The cutting process is time-consuming, and the rate of material utilization is low. Another issue is that the intermetallic compounds in the joint center which deteriorate the shear resistance cannot be eliminated completely, which makes the quality of GH4169 weldments unstable. In order to find a new method for batch welding GH4169 with high efficiency, reliability, and low consumption, the TLP welding of GH4169 alloy was studied by using BNi-2 solder paste in this paper. The solder paste is easily extruded and is not be restricted by the shape of the bonding parts. As mentioned above, the TLP method has proved to be an effective technique for obtaining excellent nickel-based alloy joints at relatively low temperatures. The TLP bonding processes of GH4169/BNi-2/GH4169 systems were carried out at 1040–1100 °C for 30 min to achieve a joint with high shear strength that was free of intermetallic compounds. The effect of bonding temperature on the microstructure and mechanical properties of the GH4169 joints was investigated.

2. Materials and Methods

In this paper, GH4169 alloys (Liaoning Jinxin Special material Technology Co., Ltd., Liaoning, China) were used as base metals. A commercial BNi-2 solder paste (Shanghai Biaorui Welding Materials Co., Ltd., Shanghai, China) was used to braze a GH4169 base alloy. The chemical compositions of the base metal and BNi-2 solder paste are given in Table 1. GH4169 ingots were sectioned into 10 mm \times 10 mm \times 4 mm and 4mm \times 4 mm \times 4 mm coupons using an electro-discharge machine. In order to remove the oxide layer, the mating surfaces of the coupons were ground up to a 1200 mesh size and then ultrasonically cleaned in acetone for 30 min. The assembly forms of the base metals and interlayer are illustrated in Figure 1a. The bonding process was carried out at 1040–1100 °C for 30 min in a vacuum furnace (2×10^{-4} Pa). The samples were first heated to 600 °C at 10 °C/min and held for 20 min to homogenize the temperatures from surface to interior. The samples were then heated to the bonding temperature at 10 °C/min. After TLP bonding, samples were cooled down to room temperature at 5 °C/min.

The cross sections of the bonded samples were cut and prepared by a standard metallographic technique. The cross section surfaces were ground with 200, 400, 600, 800, 1000, and 1200 mesh SiC sandpaper, and the grinding direction was perpendicular to the previous one after each change of sandpaper. They were then polished using 1 µm diamond paste and etched by an as-prepared etching solution for 10–15 s. The etching solution was a mixture of alcohol, hydrochloric acid, and nitric acid with a volume ratio of 1:1:1. The cross section surfaces were cleaned with anhydrous alcohol and dried in blowing air. If necessary, optical microscopy (OM) was used to make sure there were no scratches on the observed surface and the grain boundaries were clear. Microstructure characterization and composition analysis of different joints were conducted using scanning electron microscopy (SEM, Hitachi, Tokyo, Japan) equipped with an energy-dispersive spectrometer (EDS, Bruker, Karlsruhe, Germany). A shear strength test was performed with a speed of 1 mm/min on an Instron universal testing machine. Each test was repeated at least three times. A schematic illustration of the shear test fixture used in this work is shown in Figure 1b. After that, the fractographs of the bonded joints were examined by SEM.



Table 1. Chemical composition (wt.%) of the base metals and solder paste.

Figure 1. (a) Samples for microstructure observation and (b) a schematic illustration of fixture for the shear test.

3. Results and Discussion

3.1. Microstructural Characterization of the Bonded Samples

A typical microstructure of TLP-bonded GH4169 using BNi-2 solder paste at 1040 °C for 30 min is shown in Figure 2. It can be seen that the TLP joint was divided into three zones: the athermal solidification zone (ASZ), the isothermal solidification zone (ISZ) and the diffusion-affected zone (DAZ). The EDS results of different phases in ASZ are listed in Table 2. Boron is a light element, which can only be qualitatively analyzed but not quantitatively analyzed by the EDS, so it was not included in Table 2.



(a)

(b)

Figure 2. SEM (**a**) micrographs of the transient liquid phase (TLP) bonded GH4169/BNi-2/GH4169 at 1040 °C for 30 min; and (**b**) A magnified image of the white square in (a).

Zone	Ni	Cr	Fe	Nb	Mo	Ti	Si	Suggested Phase
А	71.49	18.44	4.29	0.31	0.91	1.18	3.39	γ-Ni solid solution
В	83.67	3.31	3.50	5.61	1.65	1.86	0.41	Ni-rich boride
С	1.10	84.18	0.84	0.94	10.83	1.63	0.49	Cr-rich boride
D	81.69	6.12	5.77	0.83	0.20	0.47	5.42	$Ni_3Si + \gamma$ -Ni solid solution

Table 2. Chemical composition (wt.%) of different zones marked in Figure 2.

It can be seen that the ISZ had a monophasic microstructure. The EDS results of zone A indicate that the ISZ was composed of a γ -Ni solid solution. Similar results have been reported by other researchers [15,18]. During the process of TLP bonding, the bonding temperature was higher than the melting point of the BNi-2 interlayer. The MPD (melting point depressant) elements (e.g., B and Si in the molten BNi-2) diffused into the base metal and the melting point of BNi-2 increased. When the melting point rose to the bonding temperature, the grains of the γ -Ni solid solution nucleated on the side of the base metal and an epitaxial growth grew to the center of the joint. It should also be noted that elements such as Nb, Mo, and Ti were found in the ISZ. These elements were not included in the original composition of the BNi-2 paste (Ni-Cr-Fe-Si-B). It can be inferred that these elements were dissolved from the base metal during the bonding process. In conclusion, the formation of the ISZ can be attributed to the composition and solidifying point of the melting point change in BNi-2, which was caused by the interdiffusion between the base metal and BNi-2 interlayer.

Figure 2a demonstrates that the ASZ of the joint was composed of three different phases (marked as B, C, and D). According to the EDS results listed in Table 2, Ni-rich boride was found in zone B. During isothermal solidification, the formation and growth of the γ -Ni solid solution phase rejected excess Cr and B in the liquid phase. With the increase of Cr and B concentration the composition of the liquid phase moved to the eutectic composition. During the subsequent cooling process, a eutectic reaction occurred in the liquid phase, which resulted in the formation of Ni-rich boride and γ -Ni solid solution as a binary eutectic. A similar phase composition appeared during the TLP bonding of the IN718 superalloy conducted by Pouranvari et al. [15]. Jalilvand et al. [19] also pointed out that the formation of Ni-rich boride was due to the eutectic reaction of residual liquid phase during the TLP bonding of the IN738LC superalloy. Similarly, the existence of Cr-rich boride was found in zone C. Further increasing chromium concentration during the cooling in the liquid phase allowed the composition of the liquid phase to reach a new eutectic composition. This part of the liquid solidified to a binary eutectic consisting of Cr-rich boride and γ -Ni solid solution. This can be verified by Arafin et al.'s [17] work on the TLP bonding of IN718 and IN625.

Figure 2b shows a magnified image of zone D. There are many fine particles in this region. EDS analysis showed that the Si in zone D was as high as 5.42 wt.%. According to Ni-Si-B phase diagrams [15,18], the solubility of Si in the γ -Ni solid solution was about 4 wt.% at room temperature. It can be preliminarily concluded that these fine particles were products of precipitation rather than a eutectic reaction. No nickel silicide was found in the ISZ, which can also be explained by the fact that Si in ISZ (~3.39 wt.%) was lower than the solubility of Si in the γ -Ni solid solution. It can be inferred that these fine particles were in agreement with previous work on the TLP bonding of duplex stainless steels [15,16]. It can be concluded that athermal solidification occurred during the cooling process. The formation of ASZ due to the bonding temperature was insufficient to complete isothermal solidification.

The SEM image of the DAZ of the GH4169 joint bonded at 1040 °C is shown in Figure 3. It can be seen that extensive blocky and needle-like compounds were formed in the DAZ. The EDS results of these compounds are shown in Table 3. The Cr, Nb, and Mo contents in zone E and zone F were significantly higher than those in the base metal, which confirms that the gray blocky and needle-like compounds were Cr-Nb-Mo-rich boride compounds. Similarly, The EDS results of zone G indicated that the black blocky compounds were Ni-Cr rich boride compounds. Although both B and Si are MPD elements, the silicon content in the DAZ was very low. Silicide is not clearly seen in Figure 3 due to the smaller atomic radius of B. During diffusion, B diffused into the interstitial site and Si would take the substitutional site so the diffusion rate of B was much higher than that of Si. It can also be seen that compounds were formed only at the grain boundaries in the region far from the joint. This is because the free energy of the grain boundary is lower than that inside of the grain, and moreover, the concentration of B is relatively low in the farther region, according to diffusion theory. In conclusion, the formation of

DAZ can be explained by the diffusion of B from the BNi-2 paste into the base metal, which reacted with the strong boride formers (e.g., Cr, Nb, and Mo) in the base metal.



Figure 3. Backscatter FE-SEM images of the diffusion-affected zone of GH4169.

Table 3. Chemical composit	on (wt.%) of different z	ones marked in Figure 3
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Zone	Ni	Cr	Fe	Nb	Мо	Ti	Si	Suggested Phase
Е	22.15	24.98	11.10	22.15	17.25	1.50	0.87	Cr-Nb-Mo-rich boride
F	26.66	32.90	10.66	13.66	13.95	1.35	0.82	Cr-Nb-Mo-rich boride
G	52.98	25.18	16.64	1.57	2.19	1.32	0.12	Ni-Cr rich boride

3.2. The Effect of Bonding Temperature on the Joint Microstructure

It can be seen from Figure 4 that the eutectic compounds in the ASZ decreased with the bonding temperature increasing from 1040 to 1080 °C. When bonded at 1080 °C, the ASZ in the center of the joint disappeared completely and the joint region was only composed of the ISZ and DAZ. However, the eutectic compounds of the ASZ appeared again when the bonding temperature was further increased to 1100 °C. Considering that the ASZ was formed due to a bonding temperature that was insufficient for the completion of isothermal solidification [20], increasing the bonding temperature from 1080 to 1100 °C decreased the rate of isothermal solidification. Therefore, it can be inferred that 1080 °C is a critical bonding temperature for TLP-bonded GH4169 when using BNi-2 solder paste. Below 1080 $^\circ$ C, increasing the temperature would increase the rate of isothermal solidification. Above 1080 $^\circ$ C, increasing the temperature would decrease the rate of isothermal solidification. This can be explained with Fick's second law of diffusion: $\partial C/\partial t = D \cdot \partial^2 C/\partial X^2$. As mentioned before, the formation of the ISZ was attributed to the composition changes caused by interdiffusion between the base metal and BNi-2 solder paste. In the joint region, the change of the concentration of an element with time $(\partial C / \partial t)$ depends on both the diffusion coefficient (D) and the concentration gradient ($\partial^2 C / \partial X^2$) of this element. With an increase of bonding temperature, the diffusion coefficient increases, but the concentration gradient decreases. When the effect of temperature on the diffusion coefficient exceeds that on the concentration gradient, increasing the temperature will increase the rate of isothermal solidification. On the contrary, when the effect of temperature on the concentration gradient exceeds that on the diffusion coefficient, then increasing the temperature will decrease the rate of isothermal solidification [21,22]. Therefore, there should be a critical bonding temperature in the unsteady diffusion process of TLP bonding. For the GH4169/BNi-2 solder paste/GH4169 TLP bonding system the critical bonding temperature was 1080 °C.



Figure 4. SEM images of TLP-bonded GH4169/BNi-2/GH4169 at different temperatures: (**a**) 1040 $^{\circ}$ C, (**b**) 1060 $^{\circ}$ C, (**c**) 1080 $^{\circ}$ C, and (**d**) 1100 $^{\circ}$ C.

3.3. Shear Strength and Fractography of the Joint

Shear tests were conducted to investigate the effect of bonding temperature on the mechanical behavior of TLP-bonded GH4169 joints, and the results are illustrated in Figure 5. It can be seen that the highest shear strength (728.03 MPa) was obtained at 1080 °C. The average shear strength of the GH4169 joints at different brazing temperatures were 397.52 MPa at 1040 °C, 551.15 MPa at 1060 °C, and 572.45 MPa at 1100 °C. The maximum average shear strength is relatively high in the industrial applications of nickel-base alloys. The shear strength increased with increasing bonding temperature from 1040 °C to 1080 °C. This result is probably the consequence of increasing the width size of the ISZ and decreasing the intermetallic compounds in the joint area. The intermetallic compounds in the ASZ and the DAZ can deteriorate their mechanical properties due to their brittle nature [23]. As mentioned in the microstructural analysis, higher bonding temperatures promote the diffusion of alloying elements (e.g., Cr, Nb, Mo) from the base metal into the bonding region, enhancing the solid solution (e.g., y-Ni solid solution) strengthening mechanism. As the bonding temperature increased from 1080 to 1100 $^{\circ}$ C, the effect of temperature on the concentration gradient exceeded that on the diffusion coefficient. Increasing the temperature decreased the rate of isothermal solidification, leading to the increase of harmful intermetallic compounds. It can be concluded that the maximum shear strength was achieved at 1080 °C because the ASZ disappeared and the intermetallic compounds in the centerline of the joints were eliminated completely.



Figure 5. Effect of bonding temperature on the shear strength of TLP-bonded GH4169/BNi-2/GH4169 joints.

In order to study the fracture modes of joints with different structures and different shear properties, the fractographs were also investigated by SEM after the shear tests. The cross section and fracture surface of the TLP-bonded samples at 1040 and 1080 °C are shown in Figure 6. According to the cross-section image of the sample bonded at 1040 °C (Figure 6a), fracture occurred along the central area of the joint where the ASZ existed. The morphology of the fracture surface in Figure 6c showed that the fracture mode of this sample was brittle fracture. Therefore, it can be deduced that the boride compounds in the ASZ were the chief culprit in the failure of joints due to their hard and brittle nature. Crack initiation and propagation induced by stress concentration around these boride compounds ultimately lead to the failure of joints. This can be verified by Jamaloei et al. [23] in the case of TLP bonding between IN718 and IN600. Other joints bonded at 1060 and 1000 °C, which contained the boride compounds in the joint center, showed similar fractography.



(b)

Figure 6. Cont.





Figure 6. SEM images of the (a,b) cross section and the (c,d) fracture surface of TLP-bonded GH4169/BNi-2/GH4169 joints at 1040 °C (a,c) and 1080 °C (b,d).

However, without the ASZ in the central area of the joint, the sample bonded at 1080 °C showed a different fracture behavior. According to the cross-section image in Figure 6b, a fracture occurred along the DAZ of the joint where the intermetallic compounds existed. The intensive dimples in the fracture surface (Figure 6d) indicated that the fracture mode of the sample bonded at 1080 °C was ductile fracture. This can be attributed to the completion of isothermal solidification. The intermetallic compounds in the DAZ were the source of the cracks and the main cause of joint fracture.

4. Conclusions

For the joints brazed at 1040 °C, the athermal solidification zone (ASZ), the isothermal solidification zone (ISZ), and the diffusion-affected zone (DAZ) could be distinguished in the joint region. The ISZ was a γ -Ni solid solution. The ASZ consisted of Ni-rich boride, Cr-rich boride, and the precipitation of nickel silicide. The DAZ consisted of Ni-Cr-rich boride and Cr-Nb-Mo-rich boride compounds. With increasing bonding temperature from 1040 to 1080 °C, the thickness of the ASZ decreased and boride intermetallic compounds were eliminated in the bonded samples at 1080 °C. By further increasing the bonding temperature, the ASZ appeared again. The bonding temperature of 1080 °C was recommended as a critical bonding temperature for TLP-bonded GH4169 when using BNi-2 solder paste. The maximum shear strength (728.03 MPa) was obtained when the sample bonded at 1080 °C. The boride compounds in the ASZ and the intermetallic compounds in the DAZ were the main cause for the formation and propagation of cracks. The fracture mode of the sample bonded at 1040 °C was brittle and the fracture path was along the ASZ. However, the fracture mode of the sample bonded of C was ductile, and the fracture occurred along the DAZ.

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